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(REV. 05/03) <b>U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE</b>  <b>INFORMATION DISCLOSURE CITATION</b> <i>(Use several sheets if necessary)</i>	ATTY. DOCKET NO.  EISEN-004XX		APPLICATION NO.  <b>10/574204</b>
	APPLICANT: Volkmar Stenzel et al.		
	FILING DATE Herewith	TC ART UNIT	

**U.S. PATENT DOCUMENTS**

EXAMINER INITIAL	DOCUMENT NUMBER	PUBLICATION/ ISSUE DATE	NAME	CLASS	SUBCLASS	FILING DATE
/M.B./	* US 2002/098257	07-2002	Ikeda et al.			

**FOREIGN PATENT DOCUMENTS**

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
	* WO 00/30869	06-2000	WIPO			
	* DE 102 03 250	07-2003	Germany			
	* EP 1 003 078	05-2000	European Pat. Off.			
	* EP 1 366 888	12-2003	European Pat. Off.			
	* JP 03 203633 <u>Abstract</u>	09-1991	Japan			
	* DE 42 07 210	09-1993	Germany			
/M.B./	** DE 196 13 383	08-1997	Germany			
/M.B./	** EP 0 205 289	12-1986	European Pat. Off.			
/M.B./	** DE 299 23 870	07-2001	Germany			
/M.B./	** DE 101 08 469	09-2002	Germany			

**OTHER DOCUMENTS** (including Author, Title, Date, Pertinent Pages, etc.)

/M.B./	** Mehnert, Reiner; Sobottka, A.; Elsner, Ch.: "Microstructured Polyacrylate Surfaces Generated by UV&EB Curing," Proc. RadTech Europe 2001, (Exhibition & Conference for Radiation Curing, October 8-10, 2001, Basle, Switzerland), pp. 603-608.

**EXAMINER**

/Margaret Brodie/ (02/24/2009)

**DATE CONSIDERED**

\*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

CLG/mc/334412.1

\* **References furnished by International Bureau (PCT/EP2004/052383)**\*\* **References enclosed**